Correction to: Novel Control of the Synthesis and Band Gap of Zinc Aluminate (ZnAl₂O₄) by Using a DC/RF Sputtering Technique

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Due to an oversight, the Surname of Haya Alhummiyany was incorrectly spelled in the published online version. The correct surname is “Alhummiyany”, instead of “Alhummi-nay”. The correct spelling is also shown above.

The online version of the original article can be found at
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